Applications are invited for admission in September 2019 to the programme leading to the degree of Master of Laws in Technology and Intellectual Property Law. The Master of Laws in Technology and Intellectual Property Law curriculum extends over one academic year of full-time study, or over two academic years of part-time study. Applicants are advised to visit the website of Faculty of Law for details of the programme. Applicants must (a) comply with the General Regulations (b) hold a degree of Bachelor of Laws with at least second class honours or an equivalent qualification accepted by the University for this purpose; or (c) hold a degree in a discipline other than law with at least second class honours accepted by the University for this purpose and have at least two years relevant experience and professional qualifications; or (d) have obtained either the Common Professional Examination of England and Wales or the Common Professional Examination Certificate of this University, provided that in either case a second class honours degree or a qualification of equivalent standard of this University or another comparable institution accepted for this purpose has also been obtained. (e) for a candidate who is seeking admission on the basis of a qualification from a university or comparable institution outside Hong Kong of which the language of teaching and/or examination is not English, shall satisfy the Faculty English language requirement with one of the following recognized English tests: (i) Test of English as a Foreign Language (TOEFL): A score of 593 or above (paper-based test) or 97 or above (internet-based test) (ii) International English Language Testing System (IELTS): Band 7 or above with no subtest below 6.5 An application for exemption from the above requirements shall be considered on a case by case basis. Applications can be submitted via our taught postgraduate on-line application system at https://aal.hku.hk/tpg/programme/master-laws-technology-and-intellectual-property-law. You are required to submit the following documents to the Faculty of Law (LLM(T&IPL) Admissions Team) (at 10/F Cheng Yu Tung Tower, Centennial Campus, The University of Hong Kong, Pokfulam Road, Hong Kong) by 12:00nn, Wednesday, May 15, 2019: (a) Your official transcripts, certified true copy of certificates (and where appropriate certified translations in English) for all tertiary level studies; and a list of professional publications if any. Transcripts, diplomas, certificates and other submitted documents which are not in English should be accompanied by a certified translation in English. Certified translation may be provided by your home institution. (b) Two reference letters from two persons who can comment on your academic ability. Ideally, at least one reference should be from a former university teacher who can comment knowledgeably on your academic performance and on your ability for pursuing postgraduate study in law. Your application will not be considered until both references have been received. It is therefore in your interests to ensure that your referees' references reach the Faculty of Law before the deadline. Remark: Please note that all supporting documents once submitted will not be returned and will be destroyed if the application is unsuccessful. Applicants will be notified of the outcome of their applications in writing by July 31, 2019. If you have not heard from us by August 15, 2019, you may wish to contact the Faculty of Law Office to enquire about the results by email at lawpgs@hku.hk. The tuition fees for the academic year 2019-20 will be HK$153,300 per annum for full-time student and HK$76,650 per annum for part-time student and are subject to the University's approval. Financial assistance is available for local full-time postgraduate students and enquiries should be made to the Student Financial Assistance Agency, 11/F Cheung Sha Wan Government Offices, 303 Cheung Sha Wan Road, Kowloon.
The closing date for applications is **12:00nn, Wednesday, May 15, 2019**. Late applications will only be considered if places remain open.

February 2019